



**RESEARCH**

ALEXANDRU IOAN CUZA UNIVERSITY OF IAȘI



**RAMTECH**

Research Center on Advanced  
Materials & Technologies

# Investigation of the functional properties of ferroelectric/multiferroic systems

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DIELECTRICS  
FERROELECTRICS  
& MULTIFERROICS  
GROUP



# Outlook



## 1. Introduction

## 2. Electrical characterisation of BiFeO<sub>3</sub>-based multiferroic systems by impedance spectroscopy (IS)

- Precision LCR Meter
- Impedance/Gain-Phase Analyzer

## 3. Preparation of BiFeO<sub>3</sub> multiferroic micro/nanostructures

- Hydrothermal synthesis

## 4. PZT –based multiferroic thin films

- RF magnetron Sputtering

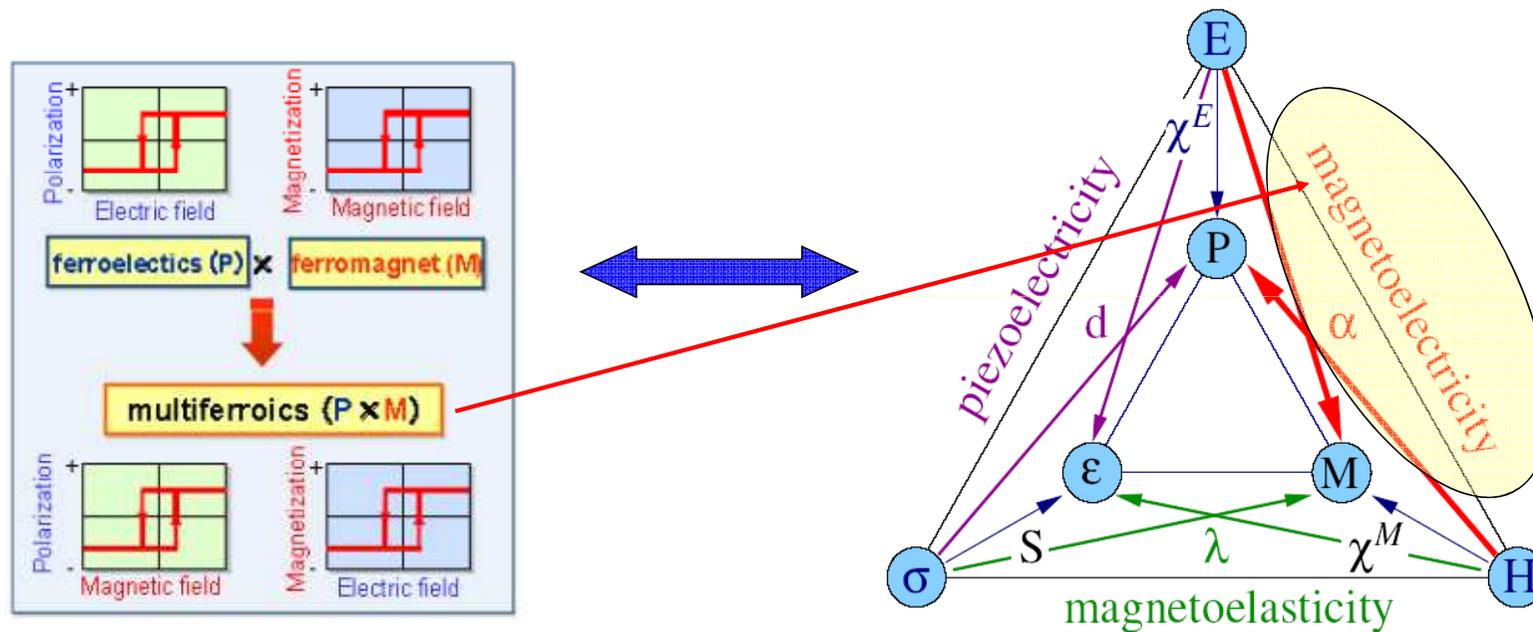
## 5. Fabrication of PPLN samples

- e-field poling method

# Introduction

PhD degree in Physics in 2012 with thesis title “*Study of the electrical and magnetic properties of single phase and composite multiferroic systems*”, Supervisor Prof.Dr.Liliana Mitoseriu

- **Magnetolectrics multiferroics**=Co-existence of both ferro/ferri/antiferroelectric and ferro/ferri/antiferromagnetic order in a certain range of temperatures and coupling between them (ME effect).



# Why multiferroic materials?

## Magnetolectric Multiferroics:

→ trends in the microelectronic industry:

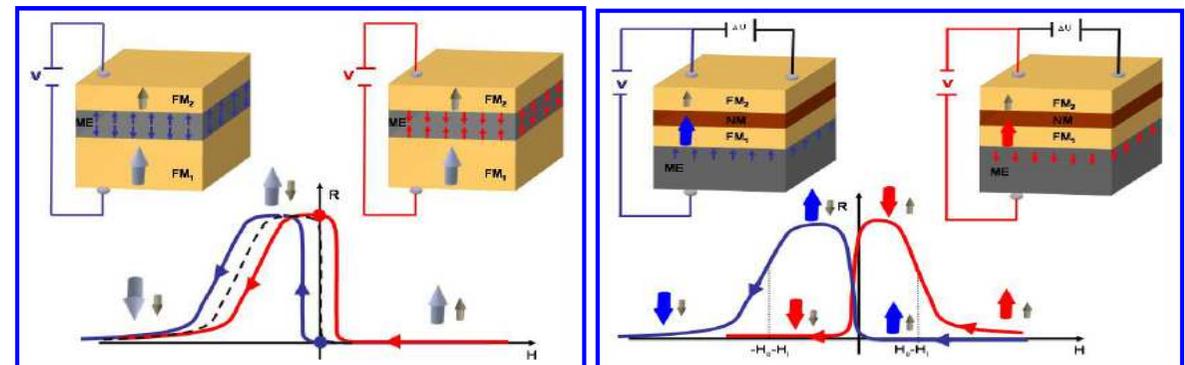
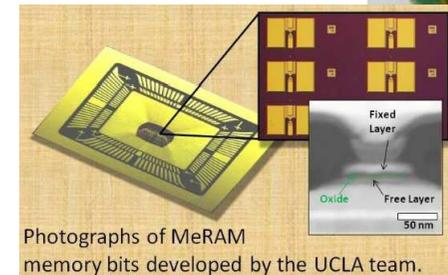
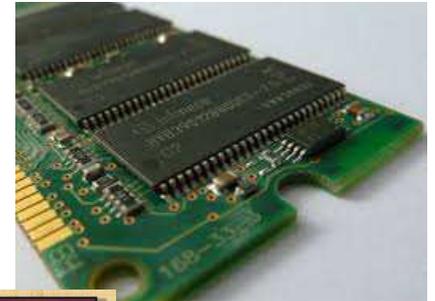
- Miniaturized components with multifunctional properties

## Applications:

- ME sensors, transducers, etc.
- Multiple state memory elements (writing/reading/deleting with E, H fields and optically)
- Spintronics

## Requirement:

- ME materials must exhibit high ME coefficients at room temperature



➤ C. Binek, B. Doudin, "Magnetolectronics with magnetolectrics", J. Phys.: Condens. Matter 17, L39–L44 (2005)

# 1. Electrical characterisation of BiFeO<sub>3</sub>-based multiferroic system by impedance spectroscopy (IS)

## ➤ Precision LCR Meter



Direct measured: R, X, C  
Calculated:  $\epsilon'$ ,  $\text{tg}\delta$ ,  $\epsilon''$ ,  $M'$ ,  $M''$ ,  $\sigma$   
Frequency: 20Hz – 2MHz

Agilent E4980A Precision LCR Meter controlled via LAN with a computer (from AMON-CARPHAT Platform)

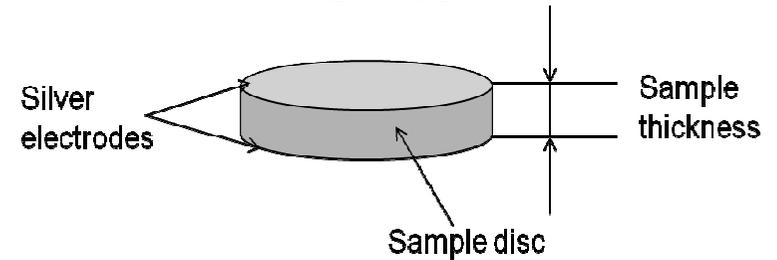
## ➤ Impedance/Gain-Phase Analyzer



Direct measured:  $\nu$ ,  $\epsilon'$ ,  $\epsilon''$ ,  $\sigma$ , R, X,  
Calculated:  $M'$ ,  $M''$ ,  $\text{tg}\delta$   
Frequency: 1Hz – 1MHz

Solartron Impedance/Gain-Phase Analyzer model 1260A from the "Dielectrics, Ferroelectrics and Multiferroics" Laboratory of the "Alexandru Ioan Cuza" University

### Sample type



➤ The electrical measurements were performed on parallel-plate capacitor configuration, by applying Ag electrodes onto the polished surfaces of the sintered ceramic disks with diameters in the range of 9-10 mm and 1- 2 mm thickness.

## ➤ Precision LCR Meter

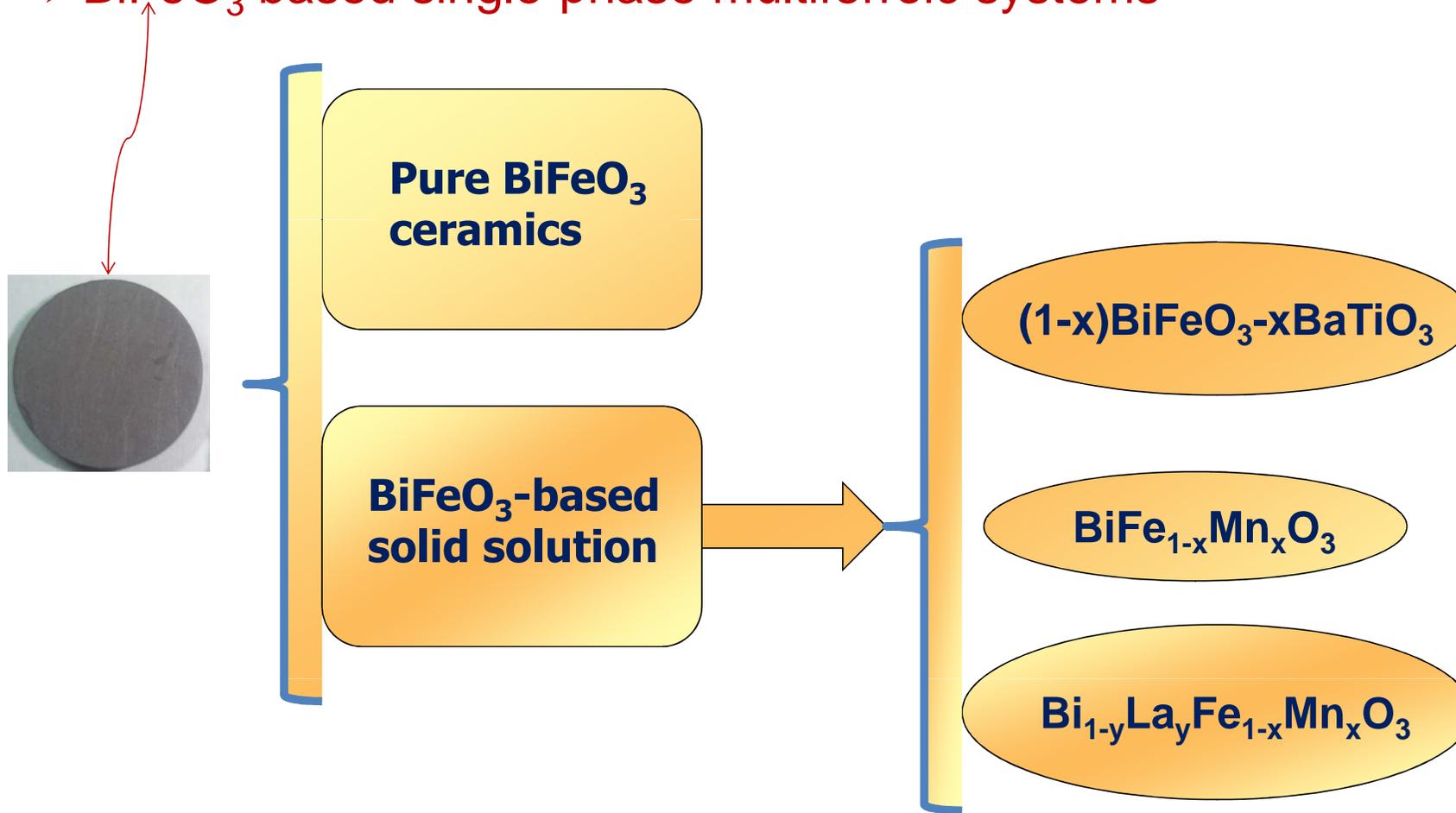


Direct measured: R, X, C, L  
Calculated:  $\epsilon'$ ,  $\text{tg}\delta$ ,  $\epsilon''$ ,  $M'$ ,  $M''$ ,  $\sigma$ ,  $\rho$   
Frequency: 20Hz – 20MHz

Wayne Kerr 6500P LCR Meter from the RAMTECH Centre of the "Alexandru Ioan Cuza" University

# Investigated multiferroic systems

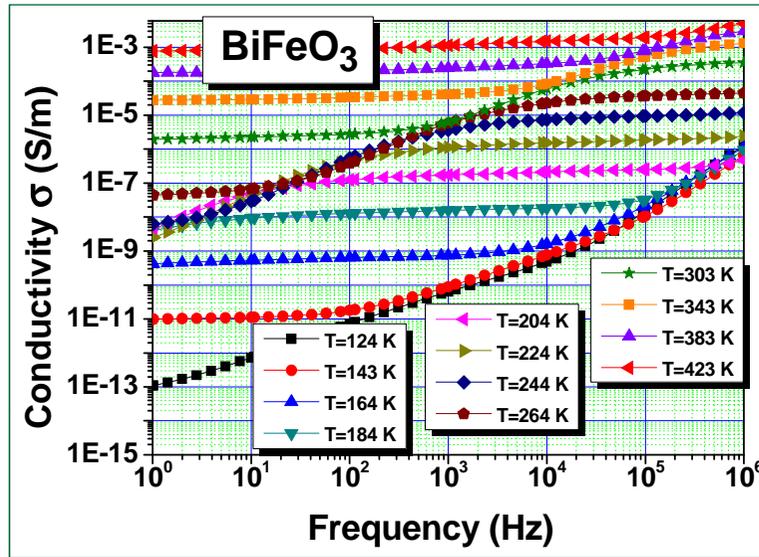
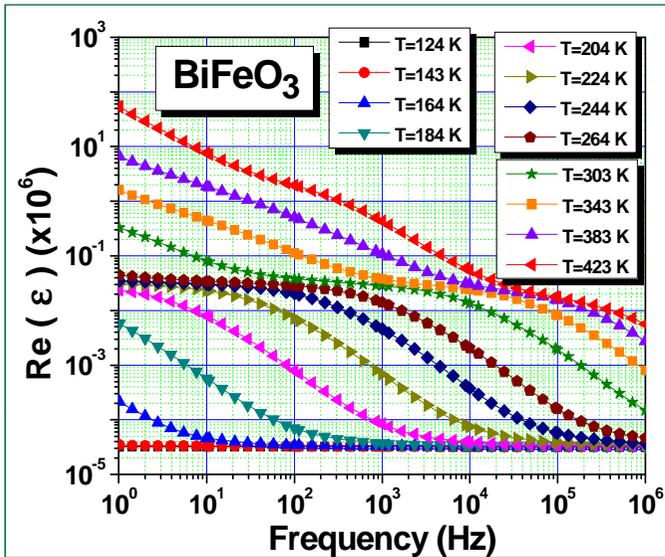
## ➤ $\text{BiFeO}_3$ based single-phase multiferroic systems



Unsolved problems:

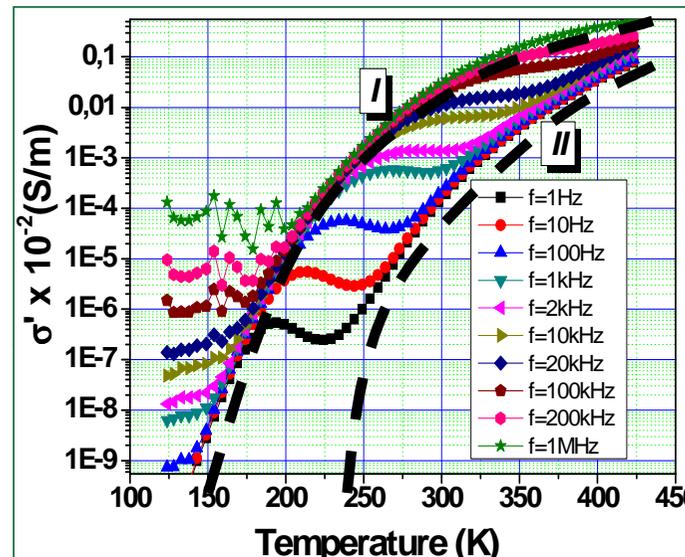
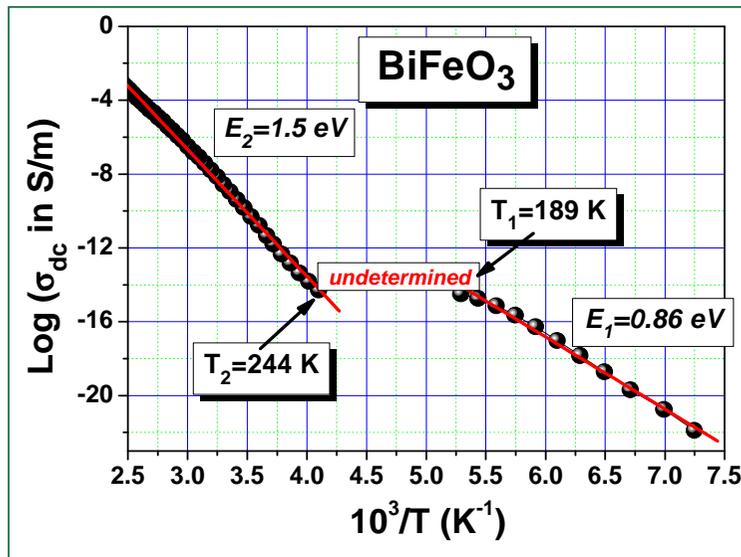
- To explain the macroscopic properties in relation with microstructure and composition of the single-phase  $\text{BiFeO}_3$  compounds
- To understand the mechanisms of conduction and dielectric relaxation

# Conductivity anomaly



➤ a strong reduction with frequency of the  $\epsilon$

➤ two region in conductivity plot :  
 1) almost constant  
 2) a large increase, separated by the range of temperature (189 – 244) K

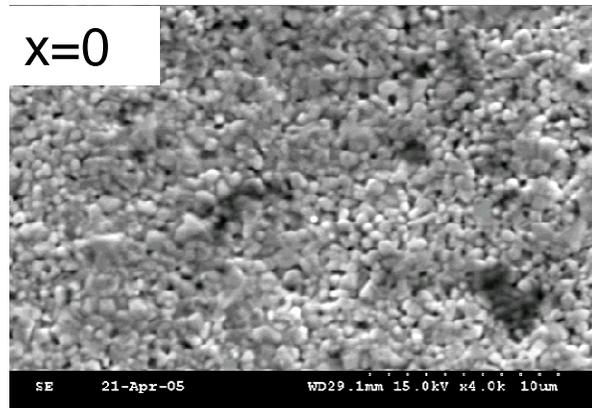
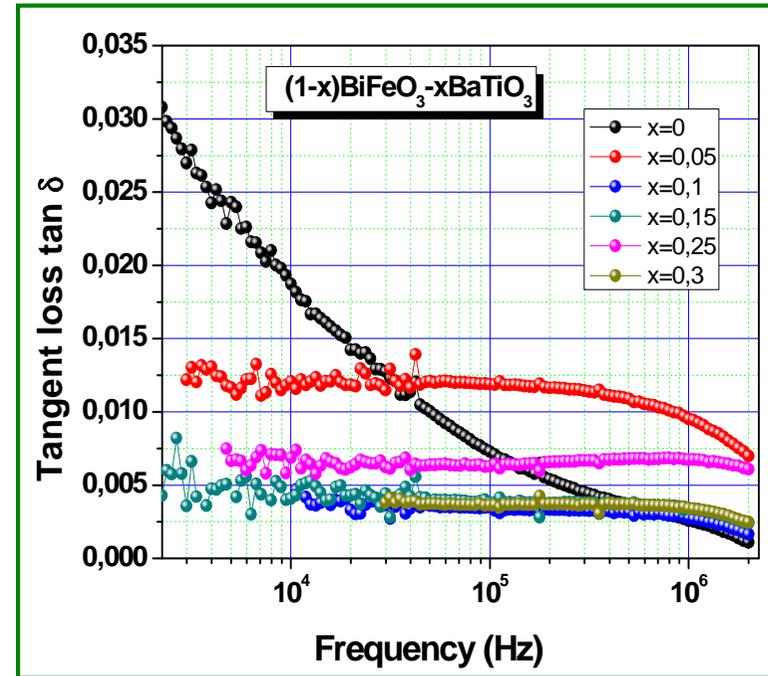
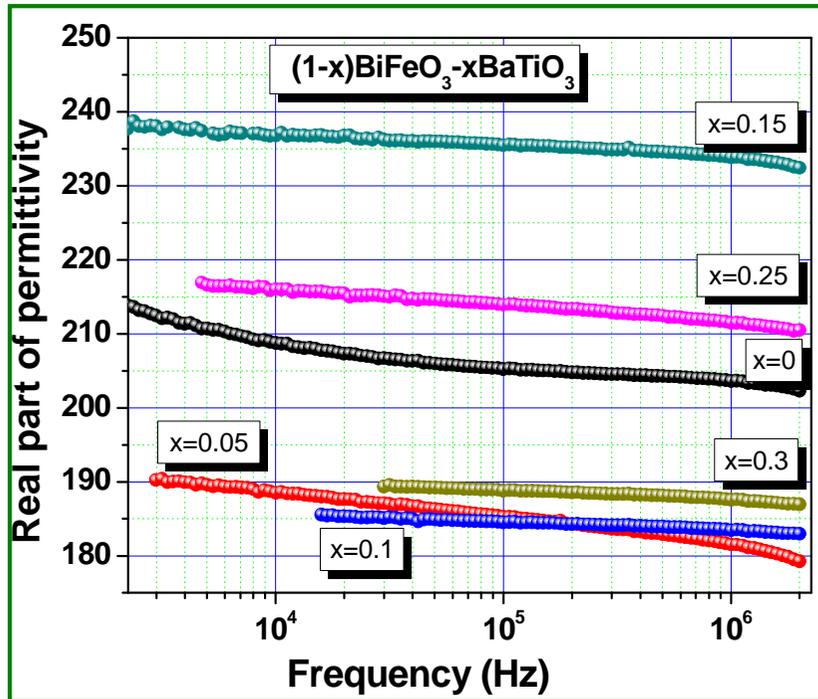


1. **Felicia Gheorghiu, Mihai Calugaru, Adelina Ianculescu, Valentina Musteata and Liliana Mitoseriu, Preparation and functional characterization of BiFeO<sub>3</sub> ceramics: a comparative study of the dielectric properties, Solid State Sciences, Solid State Sciences 23 (2013) 79-87**

2. **Lavinia Curecheriu, Felicia Gheorghiu, Adelina Ianculescu, Liliana Mitoseriu, Non-linear dielectric properties of BiFeO<sub>3</sub> ceramics, Appl. Phys. Lett. 99, (2011) 172904**

3. **Felicia Gheorghiu, Lavinia Curecheriu, Adelina Ianculescu, Mihai Calugaru and Liliana Mitoseriu, Tunable dielectric characteristics of Mn-doped BiFeO<sub>3</sub> multiferroic ceramics, Scripta Materialia 68 (2013) 305-308**

# Dielectric characteristics



⇒ Presence of  $\text{BaTiO}_3$  in solid solution results in:

- elimination of conduction mechanisms ,
- stabilization  $\epsilon'=(180-240)$  and
- reduction of dielectric losses below 3% at room temperature.

1. **Felicia Prihor**, Adelina Ianculescu, Liliana Mitoseriu, Petronel Postolache, Lavinia Curecheriu, Dragan N. and Crisan D., Functional properties of the  $(1-x)\text{BiFeO}_3-x\text{BaTiO}_3$  solid solutions, *Ferroelectrics* 391 (2009) 76 – 82
2. **Felicia Prihor Gheorghiu**, Adelina Ianculescu, Petronel Postolache, Nicoleta Lupu, Marius Dobromir, Dumitru Luca, Liliana Mitoseriu, Preparation and properties of  $(1-x)\text{BiFeO}_3-x\text{BaTiO}_3$  multiferroic ceramics, *J. Alloys Compd.* 506 (2010) 862–867
3. Adelina Ianculescu, **Felicia Prihor Gheorghiu**, Petronel Postolache, Ovidiu Oprea, Liliana Mitoseriu, The role of doping on the structural and functional properties of  $\text{BiFe}_{1-x}\text{Mn}_x\text{O}_3$  magnetoelectric ceramics, *J. Alloys Compd.* 504(2010) 420–426

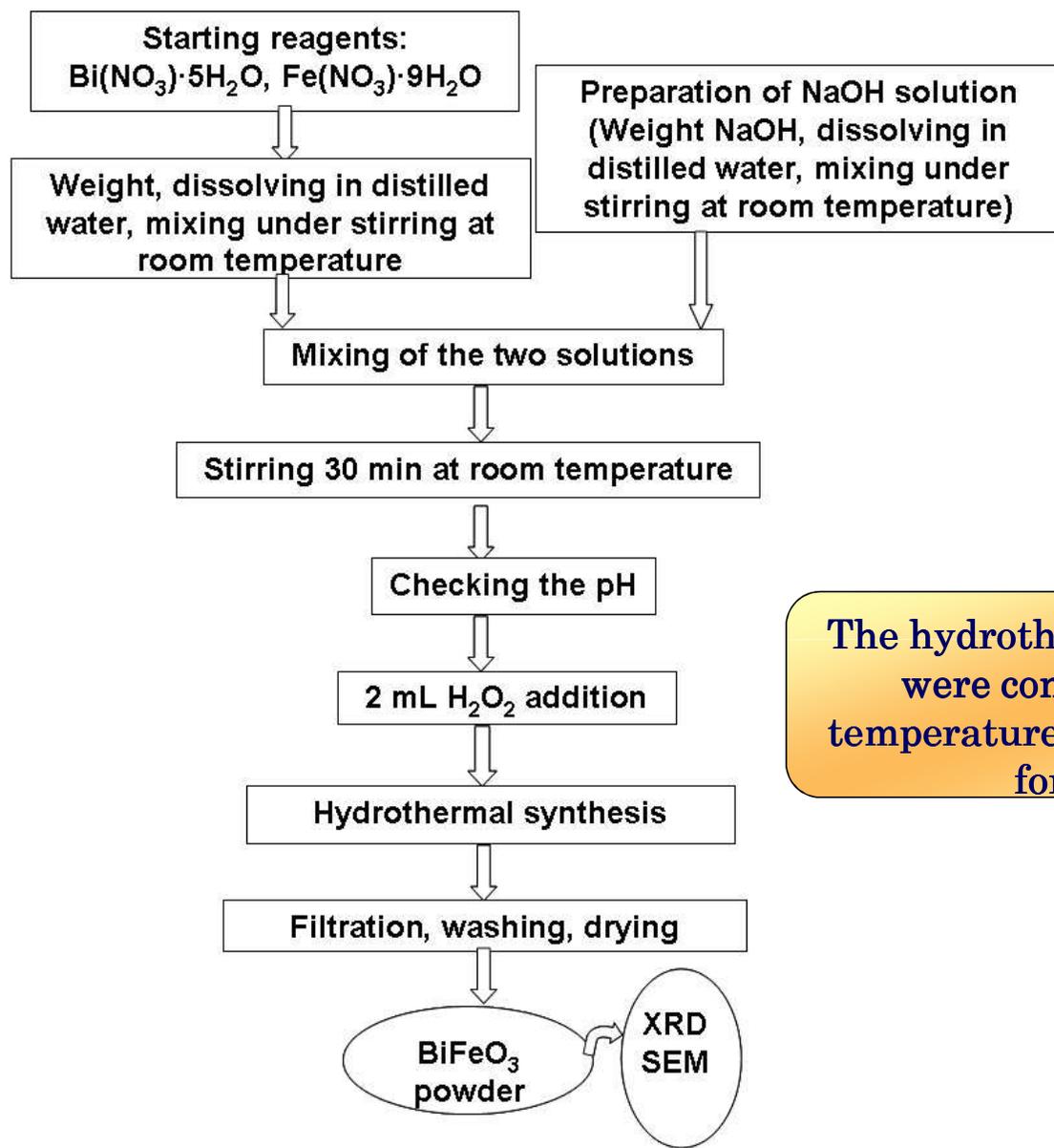
## 2. Preparation of BiFeO<sub>3</sub> micro/nanostructures

### ➤ Hydrothermal synthesis

*Univ. of Genoa & Institute of Energetics and Interphases  
IENI-CNR, Genoa, Italia*

#### Advantages:

- ⇒ **low temperatures** (< 200°C);
- ⇒ reaction takes place in a closed system under a **high pressure** as an additional parameter (besides temperature, precursors, solution pH, reaction time)



The hydrothermal treatments were conducted in the temperature range 180-220°C for 4-48h.



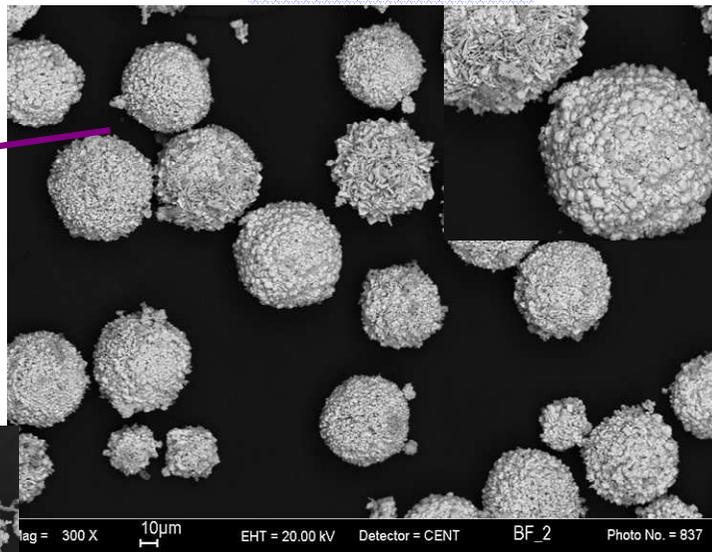
The reaction furnace and hydrothermal vessel

# Microstructural characterization

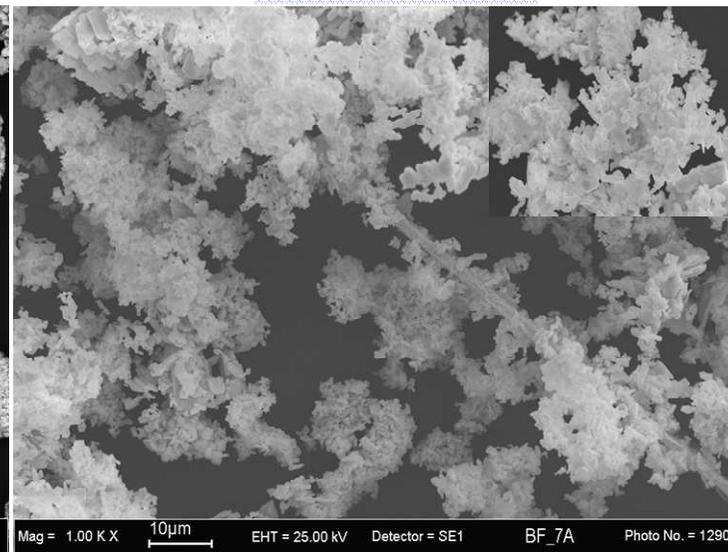
## *BiFeO<sub>3</sub> powders*



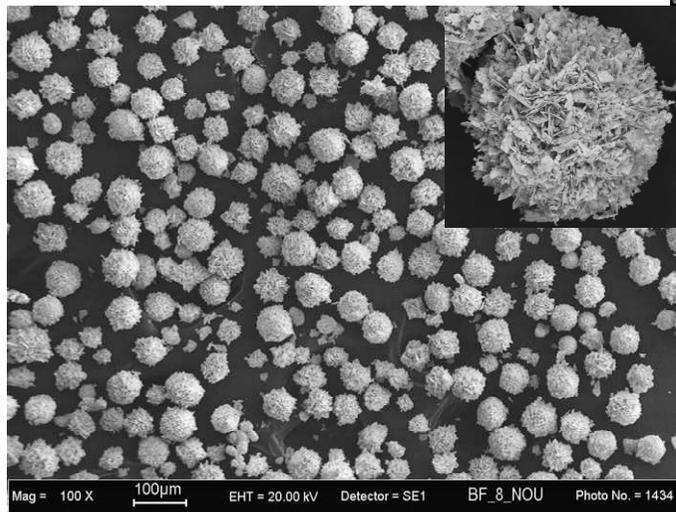
200°C/48h



220°C/48h



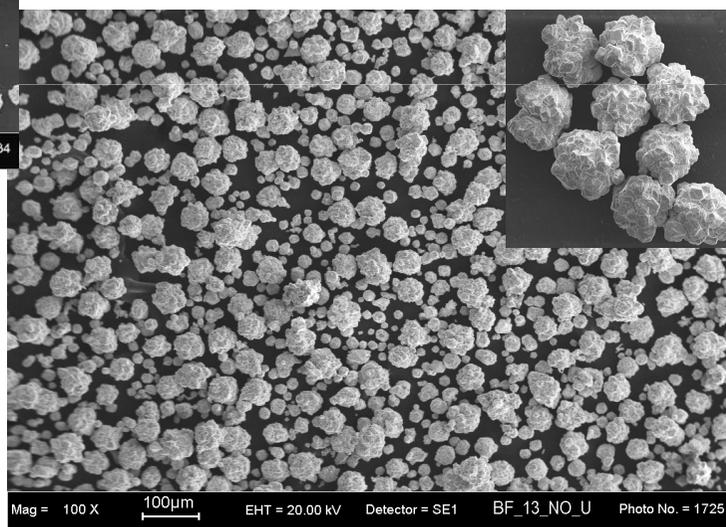
180°C/48h



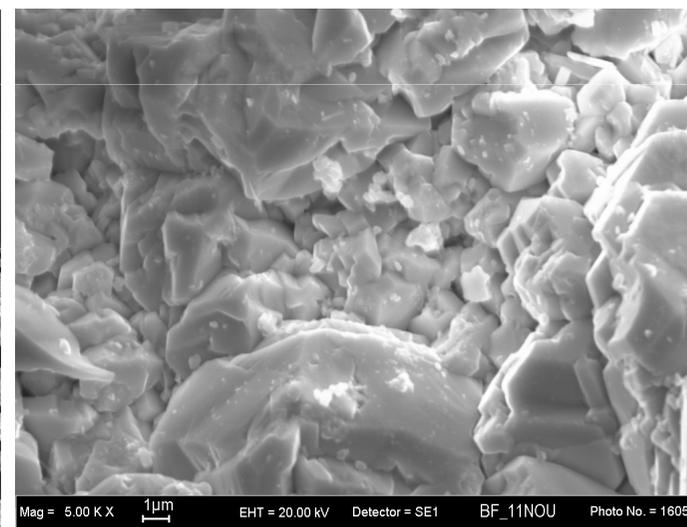
*Felicia Gheorghiu, Radu Tanasa, Maria Teresa Buscaglia, Vincenzo Buscaglia, Cristina G. Pastravanu, Eveline Popovici and Liliana Mitoseriu, Preparation of Bi<sub>2</sub>Fe<sub>4</sub>O<sub>9</sub> particles by hydrothermal synthesis and functional properties, Phase Transit 86 (7) (2013) 726-736*

Optimum conditions:

- 180°C reaction temperature,
- 8h reaction time,
- 0.001667 mol/L precursors concentration,
- 1.2 mol/L NaOH concentration.



180°C/8h



180°C/4h

# RAMTECH Centre: powders and ceramic preparation



Analytical Balance  
GH-252-EC



Ball Milling  
Grinding



Hydraulic Press-Carver



Carbolite Furnace



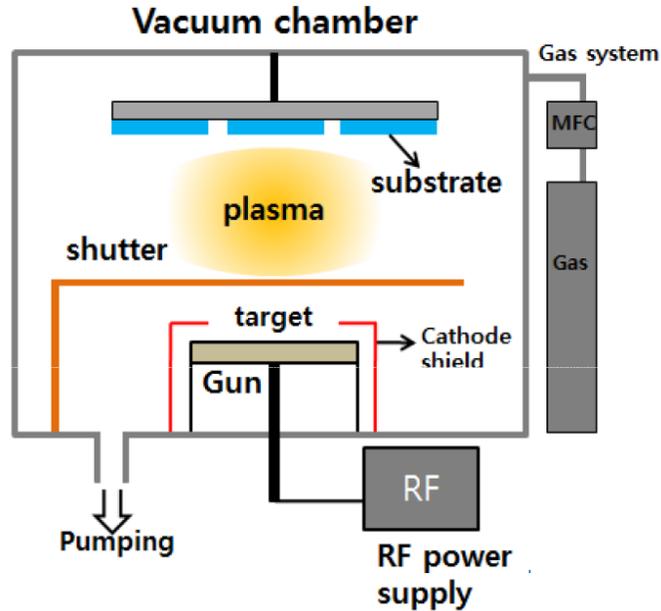
Auto Precision  
Polishing Machine



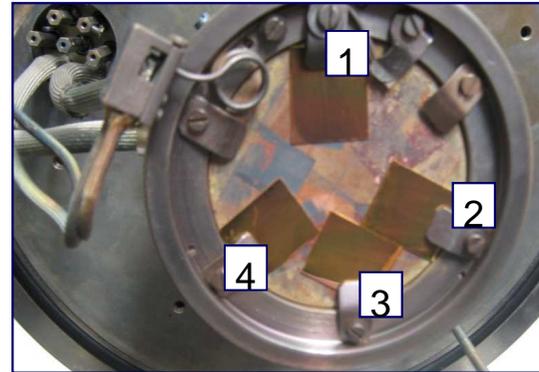
Complex impedance  
investigation

# 3. PZT –based multiferroic thin films

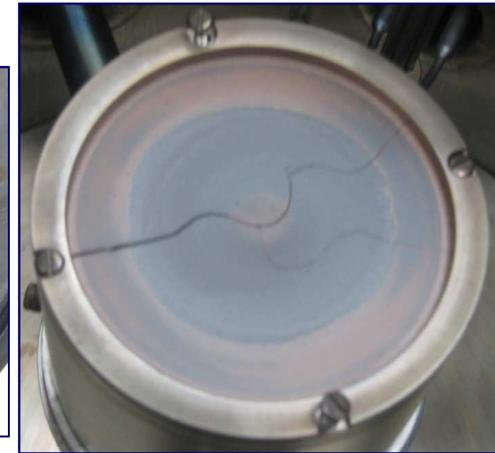
## ➤ RF magnetron Sputtering



Schematic representation of a sputtering system



Substrate positioning



The target after deposition (broken)

### Deposition conditions:

Ceramic target : Co-doped  $\text{Pb}(\text{Zr}_{0.54}\text{Ti}_{0.46})\text{O}_3$   
(Kurt J. Lesker Company)

Diameter: 3.00"

Substrate:  $\text{Au}/\text{Al}_2\text{O}_3$

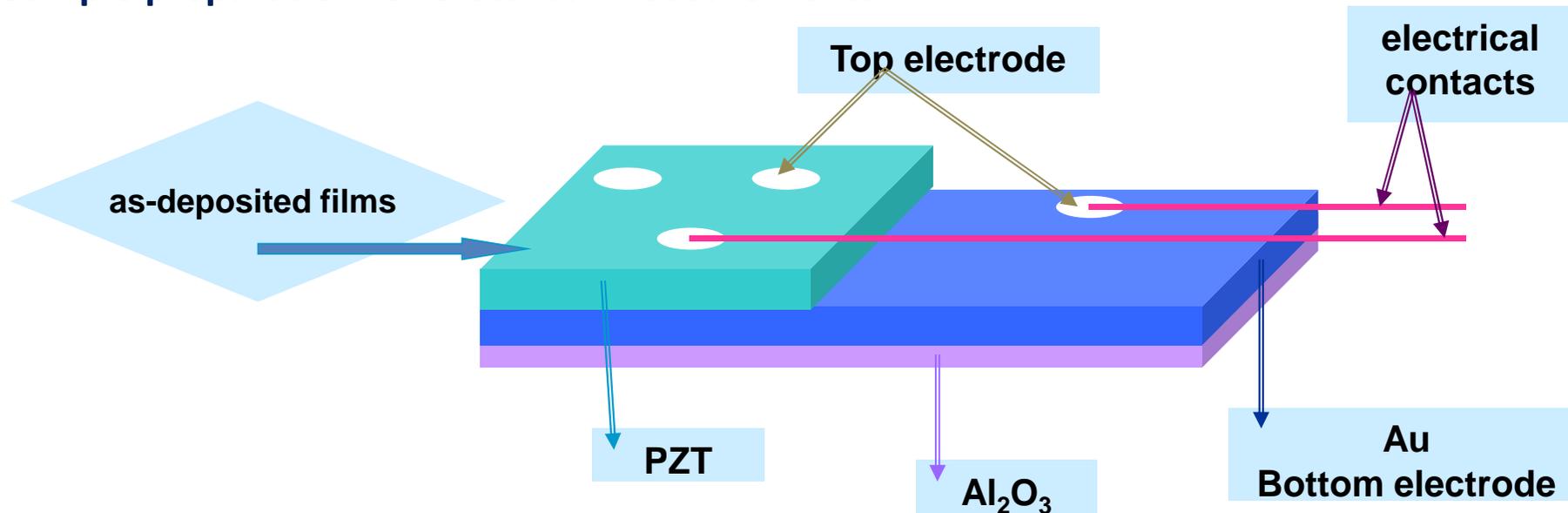
Discharge in Ar

Basic pressure:  $2 \times 10^{-6}$  mbar

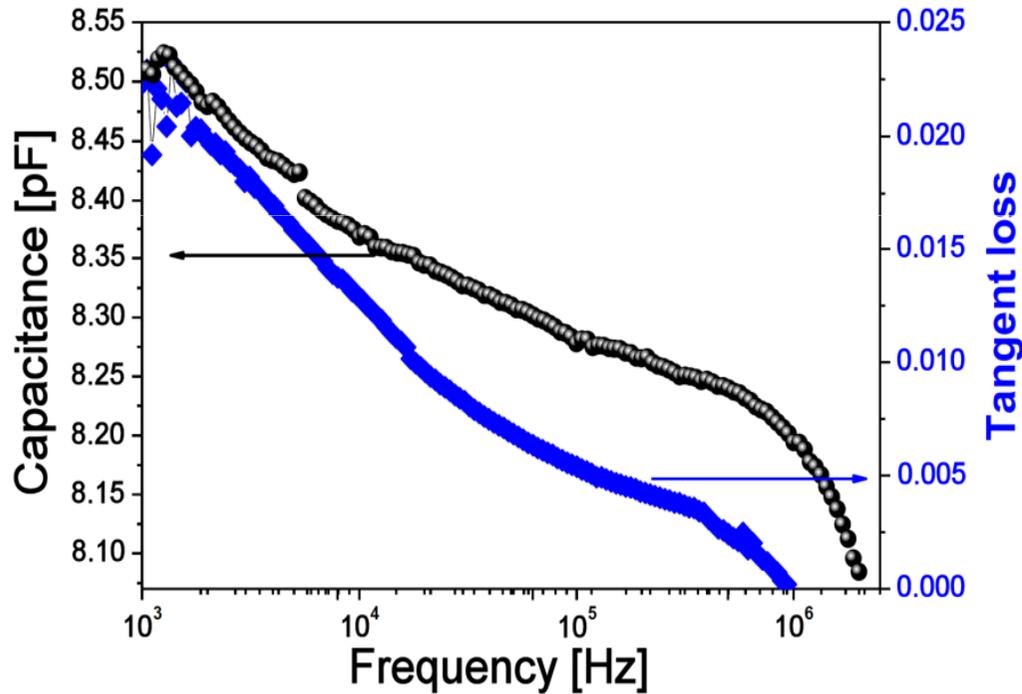
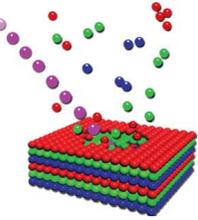
Working pressure:  $1.5 \times 10^{-3}$  mbar

Substrate temperature: 300°C

## Sample preparation for electrical measurements:

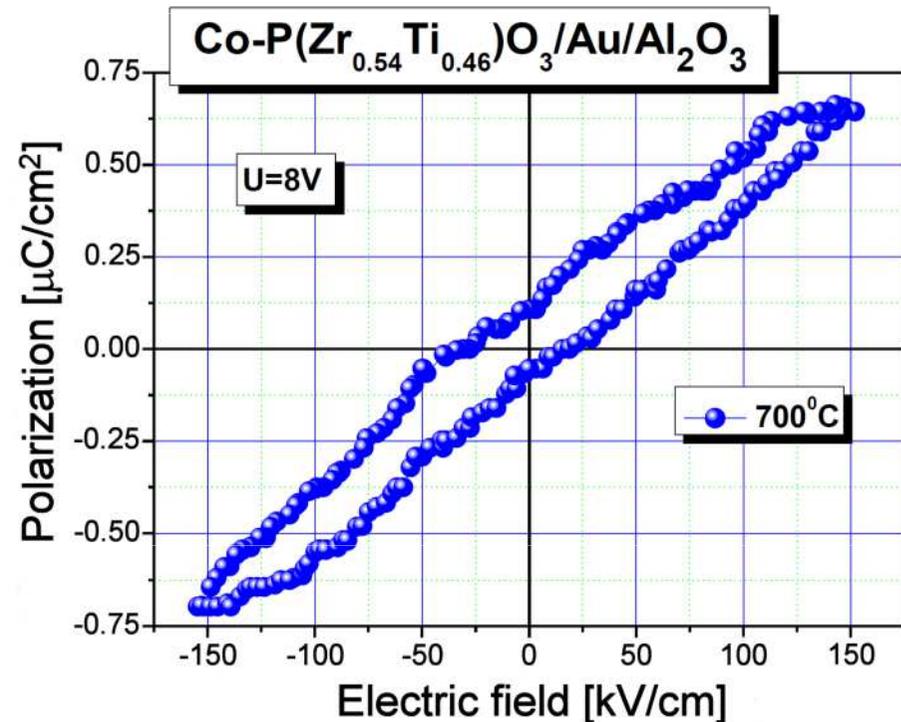


# Co-doped PZT thin films characterization



## Advantages of RF Sputtering:

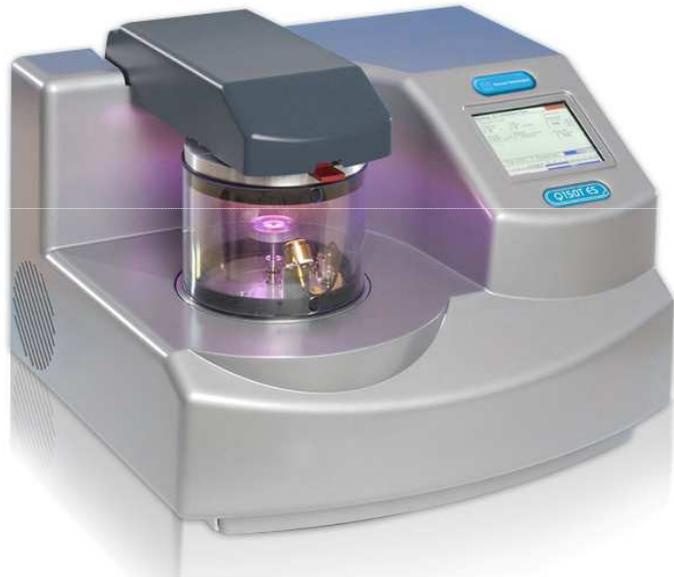
1. It works well with insulating targets
2. High efficiency: easier to keep plasma going which can operate at lower Ar pressures (1-15 mTorr)



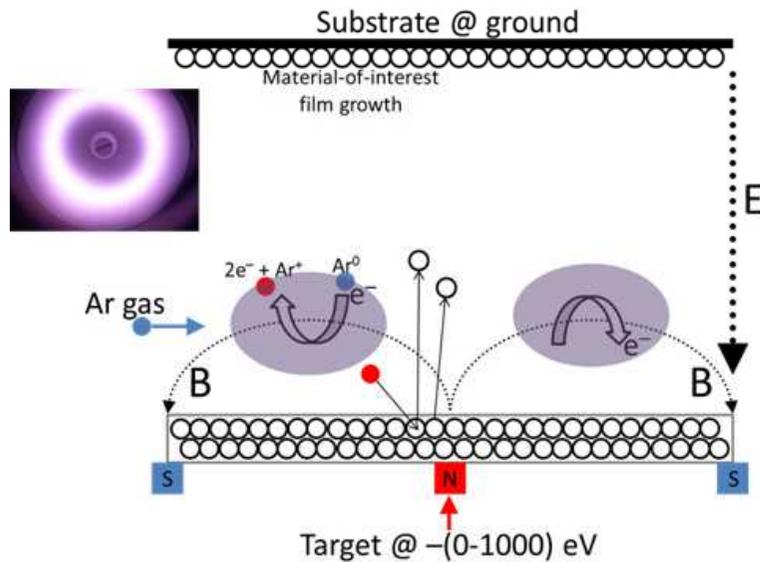
1. Raluca Frunza, Dan Ricinschi, **Felicia Gheorghiu**, Radu Apetrei, Dumitru Luca, Liliana Mitoseriu, Masanori Okuyama, Preparation and characterisation of PZT films by RF-magnetron sputtering, *J. Alloys Compd.* 509 (2011) 6242–6246
2. **Felicia Gheorghiu**, Radu Apetrei, Marius Dobromir, Adelina Ianculescu, Dumitru Luca, Liliana Mitoseriu, Investigation of Co-doped PZT films deposited by rf-magnetron sputtering, *Processing and Application of Ceramics* 8[3] (2014) 113-120

# RAMTECH Centre –thin films deposition

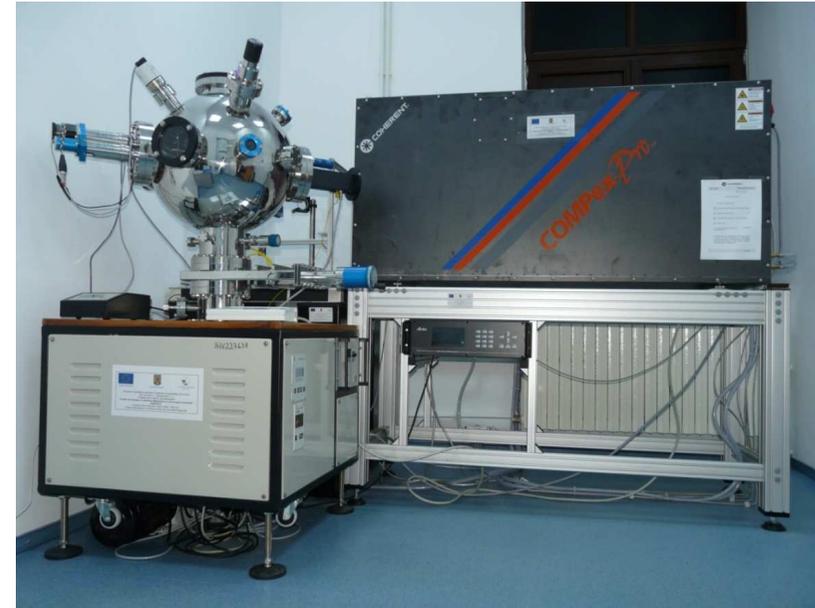
Magnetron sputtering system type  
Q150T S/E/ES



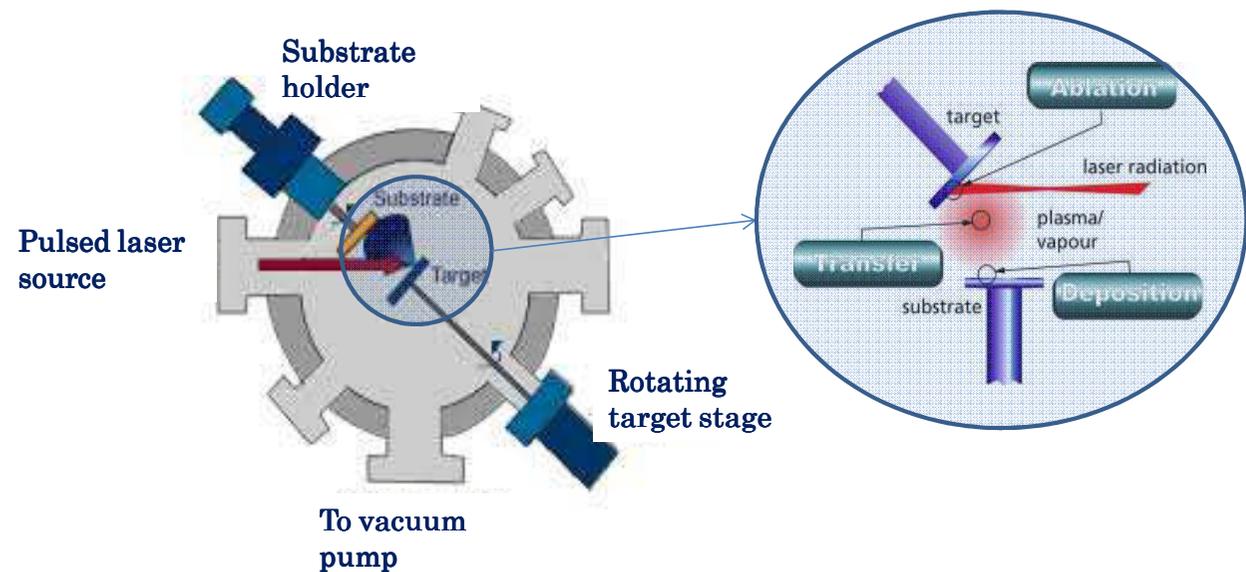
## Principle



Pulsed Laser Deposition (PLD)  
system

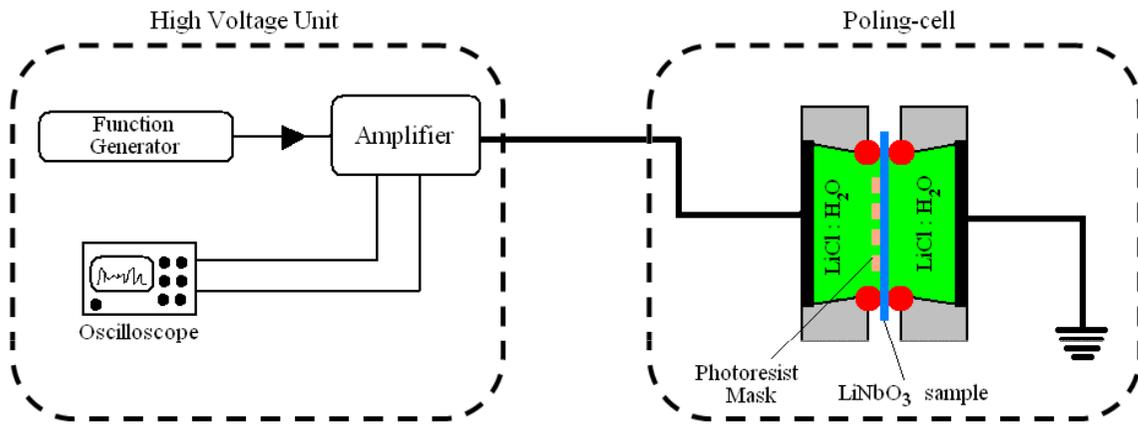


## Principle



# 4. Fabrication of PPLN samples

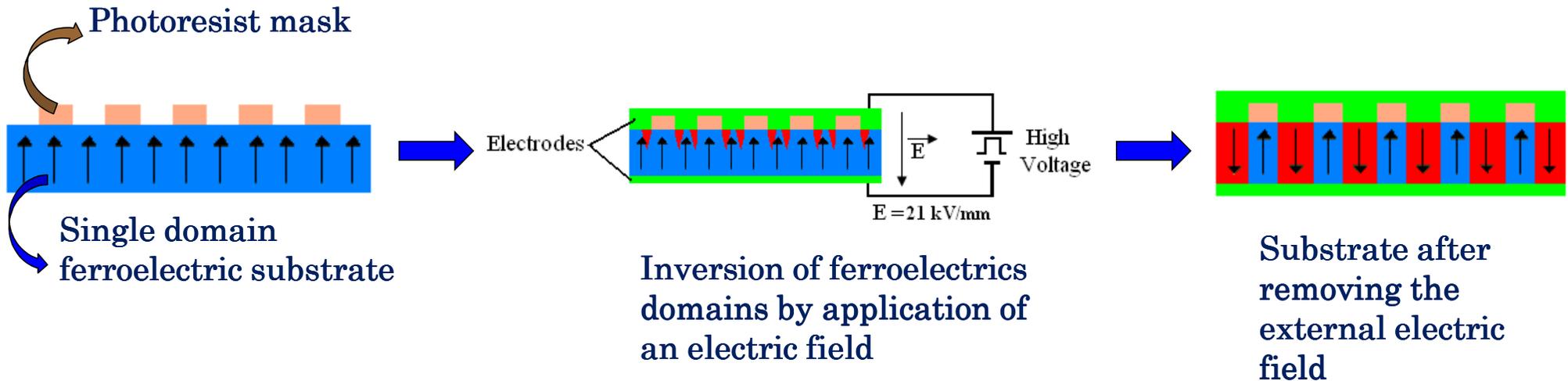
## ➤ e-field poling method



*E*-field poling setup

**PPLN=Periodically Poled LiNbO<sub>3</sub>**

## *E*-field poling method steps:



**RAMTECH Project PN-II-ID-JRP-2014:**

**“INtegrated Quantum Circuits based on non-linear waveguide Arrays”**

### Parteners:

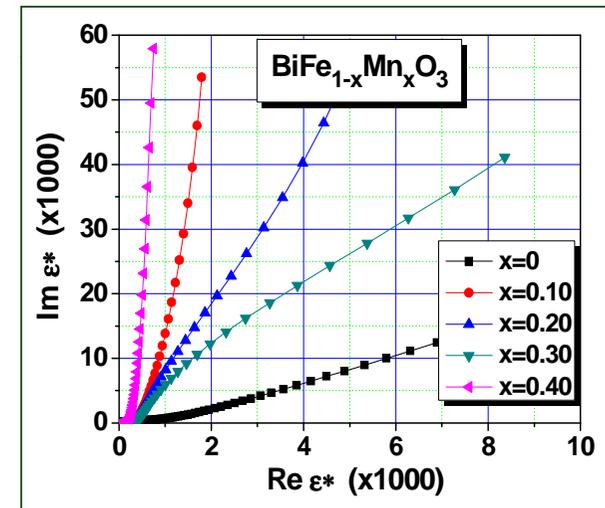
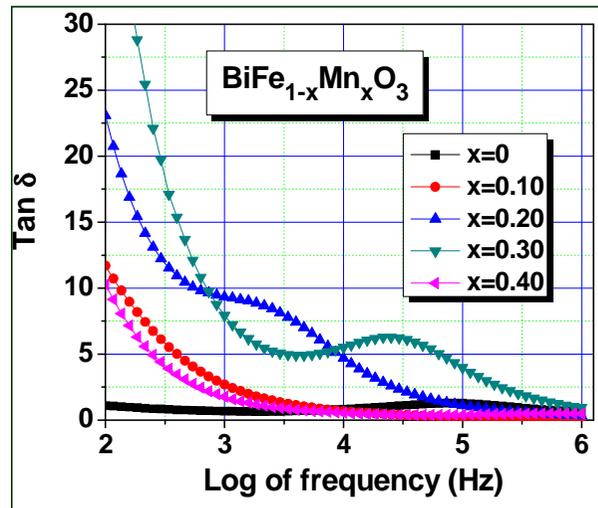
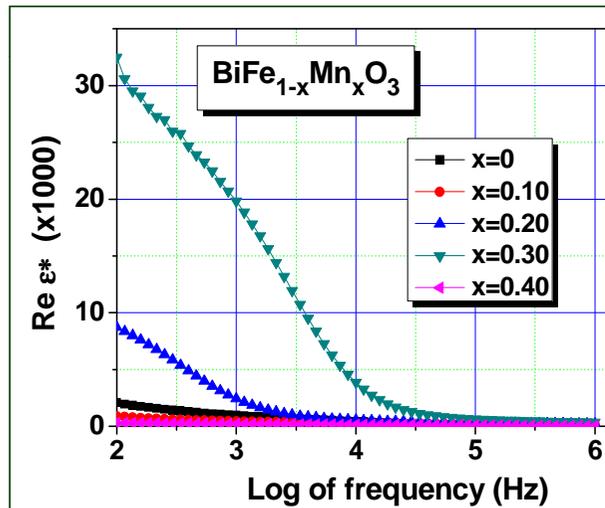
Research Center on Advanced Materials and Technologies (RAMTECH) Sciences Department, "Alexandru Ioan Cuza" University of Iași,

Laboratoire de Physique de la Matière Condensée (LPMC), Université de Nice – Sophia Antipolis, Nice, France

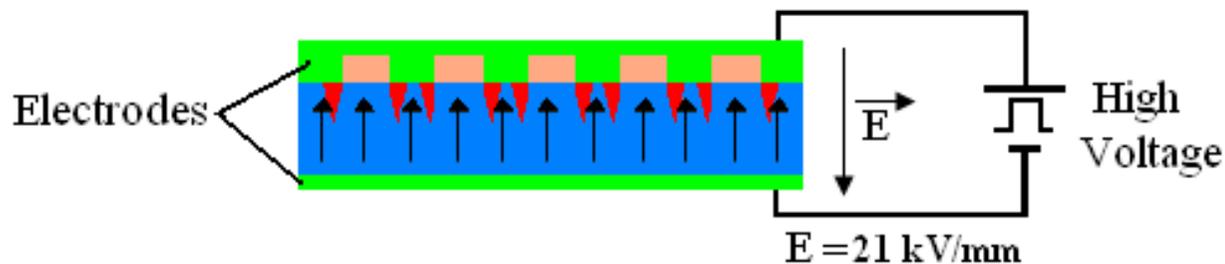
Laboratoire de Photonique et Nanostructures (LPN), Centre National de la Recherche Scientifique (CNRS), Paris, France

# Conclusions

- Electrical characterisation of ceramics by impedance spectroscopy (IS)



- Fabrication of PPLN samples by e-field poling method



Inversion of ferroelectrics domains by application of an electric field



**Thank you for  
your attention!**